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John Greivenkamp
Jun Tanida
Yadong Jiang
Haimei Gong
Jin Lu
Dong Liu
Editors

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Contents

v	<i>Authors</i>
vii	<i>Conference Committee</i>
ix	<i>Introduction</i>

AI IN OPTICS AND PHOTONICS

11342 02	An early kidney injury rapid detection device [11342-1]
11342 03	Deep learning enabled real-time modal analysis for fiber beams [11342-2]
11342 04	A method of measuring wavefront aberration with CNN [11342-3]
11342 05	Fast measurement of mid-spatial-frequency error on optical surfaces with convolutional neural networks [11342-4]
11342 06	A super-resolution method of retinal image based on laser scanning ophthalmoscope [11342-5]
11342 07	Target detection method for small defects in ink area of planar glass element [11342-6]
11342 08	Fully convolutional networks based sinogram correction for metal artifact reduction [11342-7]
11342 09	Key technologies in high efficiency and ultra precision grinding of large aperture and complex aspheric lens [11342-8]
11342 0A	A robust target recognition and tracking panoramic surveillance system based on deep learning [11342-9]
11342 0B	Hyperspectral image classification with imbalanced data based on oversampling and convolutional neural network [11342-10]
11342 0C	The effect of grinding processing parameters on aspheric small-scale waviness [11342-11]
11342 0D	Study on the basic color and color of camouflage paint in computer color matching [11342-12]
11342 0E	Research on target location method based on varistor image [11342-14]
11342 0F	Image super-resolution reconstructing based on generative adversarial network [11342-18]

11342 OH	Study on corrosion of optical glass [11342-21]
11342 OI	Small and weak target detection based on deep learning [11342-22]
11342 OJ	Target trajectory prediction based on neural network and Kalman filtering [11342-24]
11342 OK	Warship and aircraft coordinated air defense target allocation method based on attack timing [11342-25]
11342 OL	Architecture design of air-sea joint combat system based on DoDAF [11342-26]
11342 OM	Simple online and realtime tracking people with new “soft-iou” metric [11342-27]
11342 ON	Fine segmentation of fundus optic disc based on SLIC superpixel [11342-28]
11342 OO	3D object detection based on multi-view feature point matching [11342-29]
11342 OP	Using convolutional neural network for matching cost computation in stereo matching [11342-30]
11342 OQ	A small object detection method based on local maxima and SSD [11342-31]
11342 OR	Infrared long-wave multispectral image reconstruction based on auto-encoder network [11342-33]
11342 OS	Laser illumination compressed sensing imaging based on deep learning [11342-35]
11342 OT	Infrared polymorphic target recognition based on single step cascade neural network [11342-36]
11342 OU	Gas plume detection in infrared image using mask R-CNN with attention mechanism [11342-39]
11342 OV	Research on problems and countermeasures of the safety management about unmanned aircraft system in China [11342-40]

Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

An, Yi, 03	Ning, Jinna, 0I
Bai, Jian, 05	Ou, Hongxuan, 0U
Bo, Lei, 0F, 0Q	Peng, Xin, 0T, 0U
Bykovskii, Sergei, 0P	Peng, Zhenming, 0N
Cai, Binbin, 0U	Qi, Wenbo, 07
Cai, Lei, 0B	Qiang, Fan, 0Q
Cao, Changqing, 0I	Qin, Hanlin, 0R, 0S, 0T, 0U
Chen, Duo, 0O	Sang, Xinzhu, 0O
Chen, Xianhua, 09, 0C	Song, Jiang-peng, 0J
Chen, Zelin, 06	Sun, Guang-li, 0J
Deng, Pingyu, 0K	Tan, Meng, 07
Deng, Yuanlong, 06	Tian, Jiyao, 0D
Denisov, Aleksei, 0P	Tian, Yuan, 0R
Fan, Qiang, 0A	Varlamov, Eugene, 0M
Feng, Zhejun, 0I	Wang, Hui, 0N
Fu, Yang, 0H	Wang, Jian, 09, 0C
Gong, Bo, 0E	Wang, Jing, 05
Guo, Hongyang, 04	Wang, Jiuwang, 0H
Guo, Hongzhuang, 02	Wang, Kuiru, 0O
Guo, Nan, 0O	Wang, Li, 07
Hai, Tan, 0Q	Wang, Peng, 0O
Han, Yu, 08	Wang, Qiang, 04
He, Dong, 04	Wang, Ting, 0I
Hou, Jing, 05	Wang, Xingzheng, 06
Hu, Zhuangzhuang, 0T, 0U	Wang, Yan, 0M, 0P
Huang, Liangjin, 03	Wang, Yun, 0H
Huang, Xiao, 05	Wang, Yunhui, 0K, 0L
Huang, Yongmei, 04	Wang, Zhe, 02
Jiao, Peng, 0H	Wang, Zhengzhou, 07
Ju, Jianjun, 0D	Wei, Jin, 0V
Leng, Jinyong, 03	Wei, Jitong, 07
Li, Bingbin, 0S	Wei, Qiancai, 09, 0C
Li, Bingfei, 0L	Xi, Xiaoqi, 08
Li, Chunhuan, 0E	Xiao, Lei, 0E
Li, Jie, 0C	Xu, Hao, 0D
Li, Jun, 03	Xu, Yangjie, 04
Li, Lei, 08	Xu, Yin, 0A
Li, Ling-xiao, 0J	Xue, Bing, 0L
Li, Ying, 0S	Yan, Bin, 08
Li, Ziheng, 08	Yan, Binbin, 0O
Liang, Jin, 0U	Yang, Lijia, 03
Liu, Heng, 0D	Yang, Shuowen, 0R, 0S
Liu, Yan, 0S	Yang, Tian, 0O
Liu, Yutao, 0I	Yang, Tiejun, 0E
Luo, Guohui, 0T	Yang, Xin, 0D
Ma, Lin, 0R	Yang, Yuxin, 0S
Menshov, Sergey, 0M	Yu, Chongxiu, 0O
Nan, Jing, 0F	Yu, Xunbo, 0O
Nie, Wenxing, 0R	Yu, Yuanhua, 02

Yue, Heng, 0T
Yue, Tong, 0T
Yue, Yang, 0R, 0S
Zeng, Xiaodong, 0I
Zhan, Zhijuan, 0K, 0L
Zhang, Geng, 0B
Zhang, Jiawei, 0R
Zhang, Ning, 02
Zhang, Qinghua, 09, 0C
Zhang, Zhen, 02
Zhao, Ran, 0H
Zhao, Xuegong, 0N
Zhdanov, Andrey, 0M, 0P
Zhdanov, Dmitry, 0M
Zhou, Lian, 09, 0C
Zhou, Pu, 03
Zhou, Qing, 0K
Zhou, You, 0H
Zhu, Linlin, 08
Zhu, Mingwan, 08
Zhu, Wenrui, 0T

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Introduction

AOPC 2019, the Annual Conference of Chinese Society of Optical Engineering (CSOE), was one of the largest academic and industrialization activities in the field of optical and optoelectronic technology in China. The Organizing Committee intended to build a potential platform together with academic exchanges, industry exhibitions, and cooperation negotiations in one. There were 11 technical conferences and 38 conference sessions, and we sincerely hope that the research and development of optoelectronic technology were promoted, and that international cooperation in industry and in the optical and optoelectronic fields were enhanced.

AOPC 2019 was sponsored by SPIE and the Chinese Society for Optical Engineering; the Optical Society of Korea (OSK), Optics and Photonics Society of Singapore (OPSS), European Optical Society (EOS), Optical Society of Japan (OSJ) were the technical co-sponsors. There were also 48 Cooperative Organizations that supported the conference.

We received over 930 total contributions from more than 15 countries, including United States, United Kingdom, Germany, France, Spain, Australia, Canada, Mexico, Brazil, Japan, the Republic of Korea, Thailand, Singapore, the Russian Federation, China, and so on. There were 554 contributions published in SPIE Proceedings.

After careful discussion, we suggested four keynote speeches which were presented by famous scientists from Germany, Australia, Japan, and China. There were 110 excellent invited talks, 45 of them are from overseas, their inclusion represented a first-class level in the field of optics and photonics technology. On behalf of the Organizing Committee of AOPC, I express the thanks to all the invited speakers and authors for their contributions and supports to the conference.

Finally, on behalf of the Chairmen and the Organizing Committee of AOPC, I would like to heartily thank for our sponsors and Cooperating Organizations for all they have done for the conference, to all of the participants and friends for their interests and efforts in helping us to make the conference success. Also, thanks to the Program Committee for their effective work and valuable advice; especially the AOPC 2019 Secretariat and SPIE for their tireless effort and outstanding services in preparing the conference and publishing the Proceedings.

We are glad that AOPC 2019 had great success! Hope to see you next year!

Guofan Jin